SUBSTITUTE FORM PTO-1449 U.S. DEPARTMENT OF (MODIFIED) PATENT AND TRADEM												ATTY. SSIT-1				SERIAL NO. 10/711,649	
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	DIF	B.A	4	3	4	1	5	9 2 07/27/1982 Shortes et al.		156	643		08/04/1975				
		B.B	4	3	4	9	4	1	5	09/14/1982	DeFilippi et al.		204	14		08/28/1979	
		B.C	4	3	5	5	9	3	7	10/26/1982	Mack et al.		414	217		12/24/1980	
		B.D	4	3	6	7	1	4	0	01/04/1983	Wilson			110		10/30/1980	
		B.E	4	4	0	6	5	9	6	09/27/1983	Budde		417	393		07/27/1981	
	1	B.F	4	4	2	2	6	5	1	12/27/1983	Platts		277	206 R		12/27/1978	
	1	B.G	4	4	7	4	1	9	9	10/02/1984	Blaudszun		134	105		11/09/1982	
		B.H.	4	4	7	5	9	9	3	10/09/1984	Blander et al.		204	64		08/15/1983	
		B.1	4	5	2	2	7	8	8	06/11/1985	Sitek et al.		422	78		03/05/1982	
		B.J	4	5	4	9	4	6	7	10/29/1985	Wilden et al.		91	91 307		08/03/1983	
V		B.K	4	5	9	2	3	0	6	06/03/1986	Gallego		118	719		11/30/1984	
<u> </u>	FOREIGN PATENTS OR PUBLISHED FOREIGN PATENT APPLICATIONS																
			DOCUMENT NUMBER						Р	UBLICATION DATE	COUNTRY OR PATENT OFFICE		CLASS	SUBCLASS		TRANSLATION (YES/NO)	
	_	B.L															
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. B.Q																	
OTHER DOCUMENTS (Including Author, Title, Date, Place of Publication)																	
ML	14	B.R	B.R Z. Guan et al., Fluorocarbon-Based Heterophase Polymeric Materials. I. Block Copolymer Surfactants for Carbon Dioxide Applications, Macromolecules, Vol. 27, pp 5527-5532, 1994.														
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	/	B.T	Matson and Smith , Supercritical Fluids, Journal of the American Ceramic Society, Vol. 72, No. 6, pp. 872-874, 198 9														
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT												APPLICANT Kawamura et al.					
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(0. 0	U.S. PATENT DOCUMENTS																
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IND	MDH SA			8	8	╁┈	0	5	0	03/30/1999	Fitzgerald et al.		417	46		08/25/1998	
	L_	S.B			9	3	7	5	6	04/13/1999	Berman et al.		438	692		08/26/1997	
		S.C	5	8	9	6	8	7	0	04/27/1999	Huynh et al.		134	1.3		03/11/1997	
		S.D	5	8	9	8	7	2	7	04/27/1999	Fujikawa et al.		373 110			04/28/1997	
		S.E	5	9	0	0	1	0	7	05/04/1999	Murphy et al.	·	156	359		09/11/1996	
		S.F	5	9	0	0	3	5	4	05/04/1999	Batchelder		430	395		07/03/1997	
		S.G	5	9	0	4	7	3	7	05/18/1999	Preston et al.		8	158		11/26/1997	
		S.H	5	9	0	6	8	6	6	05/25/1999	Webb		427	534		02/10/1997	
		S.I	5	9	0	8	5	1	0	08/01/1999	McCullough et al.		134	2		10/16/1996	
		S.J	5	9	2	8	3	8	9	07/27/1999	Jevtic		29	25.01		10/21/1996	
V		S.K	5	9	3	2	1	0	0	08/03/1999	Yager et al.		210	634		06/14/1996	
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